Earth Science Technology Conference 2003

Radiation Tolerant Ultra Low Power CMOS Microelectronics: Technology Development Status

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Acknowledgement: CAMBR/U Idaho team, GSFC colleagues (J. Oberright, C. Wu, M. Johnson, K. Li, M. Xapsos, R. Muller, W. Fong, Kitt Reinhart, R. Schnur, H. Shaw, K. LaBel), LaRC colleagues (H. Benz, S. Ruggles)

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CONTENT

- ☐ Technology Background
- Performance
- ☐ Potential Impact on S/C and Science
- ☐ Future Work

Radiation Tolerant and Radiation Hard

Radiation Hard

- 1Meg rads Total Dose
- No latchup
- SEU ~ 40 LET

Radiation Tolerance

- 100K rads Total Dose
- No latchup
- SEU ~ 40 LET

RT ULP

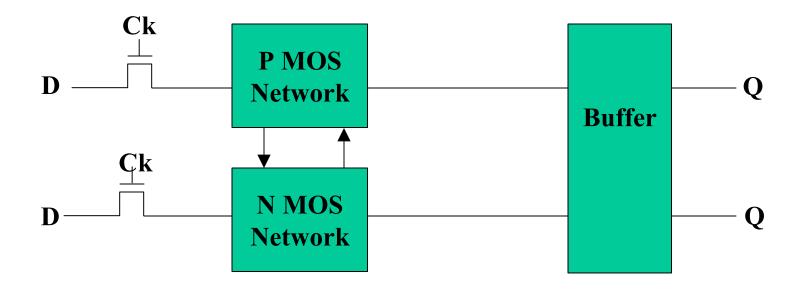
- ∼ 1 Meg rad expected
- No latchup
- SEU ~ 40 LET
- Dose Rate designed

Radiation Tolerance

- 1. SEU tolerance by electrical design
- 2. Latchup through guard bar layout
- 3. Total dose through fabrication process*
- 4. Commercial foundry based

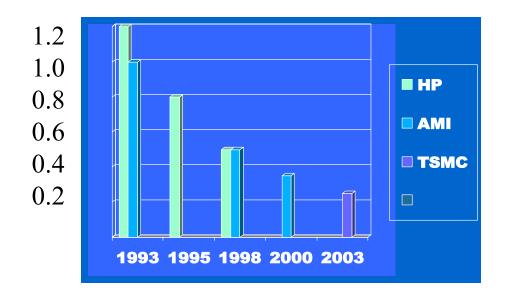
^{*} Dramatic total dose increase through Ultra Low Power design

RT Overview

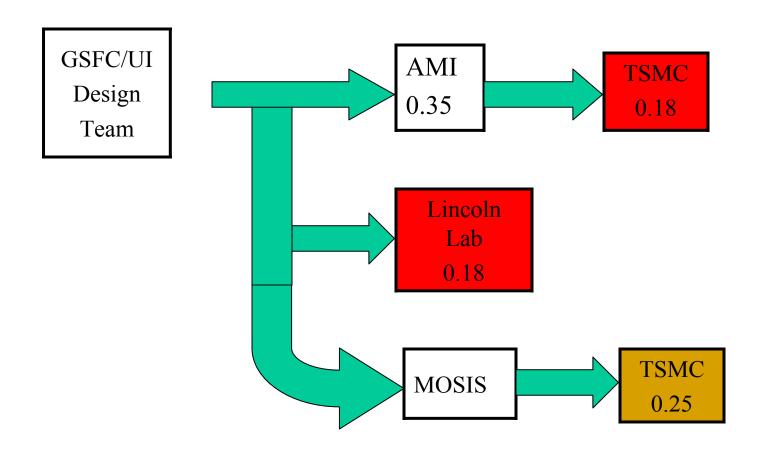


- Data stored in 2 networks
- Current flows in known direction when particle hits
- Feedback corrects faulty mode
- Incorrect state can not propagate

RT Process Experience

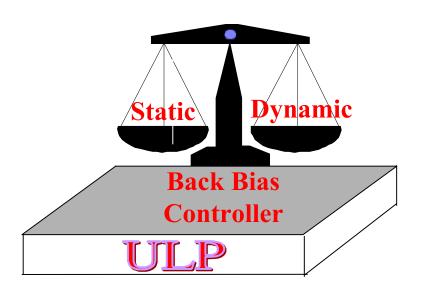


Available Foundries



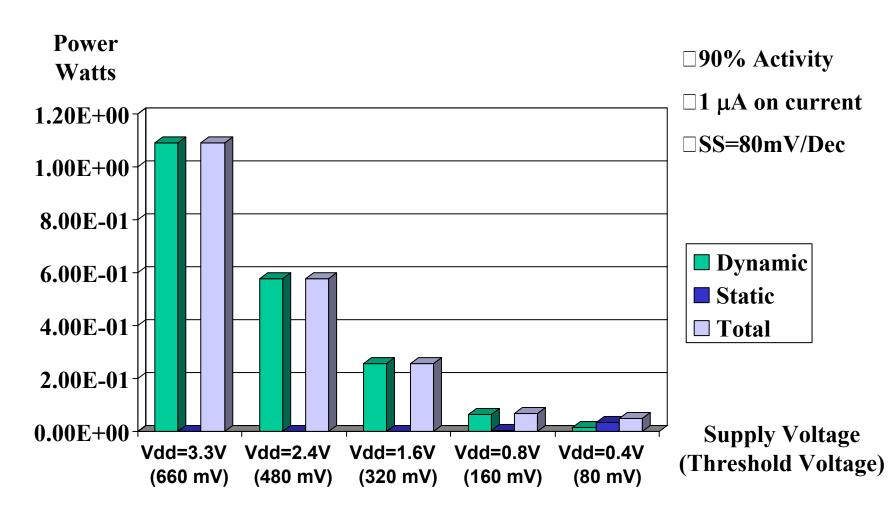
ULP Fundamentals

- Current CMOS Power (3.3V switching)
 - > 90% dynamic
 - < 10% static
- ULP (0.5V switching)
 - 50% dynamic
 - 50% static



• Results in 40:1 power reduction

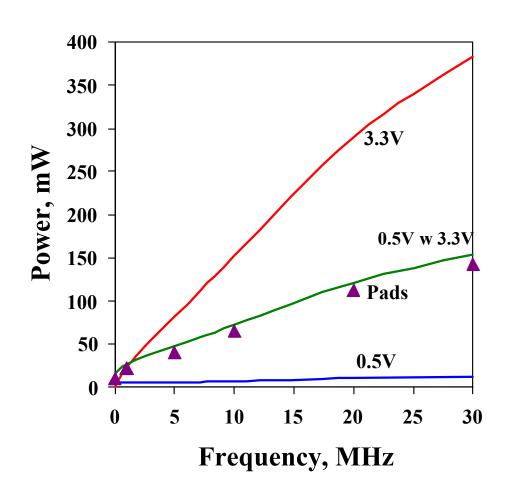
1M Transistor Design (Constant 5X Overdrive)



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Power Comparisons



- Up to 30x savings in power for ULP part
- Power savings increases with frequency
 - Static power of ULP parts exceeds that of 3.3V part
 - More power consumed switching at high voltages
- Dynamic power of ULP with 3.3V pads is much less than 3.3V part. Power consumption dominated by pad power.

Area Impact

- Main Issue in "hardening by design" is providing protection for SEU events.
 - In FPGA, configuration logic dominates chip area. Triple Modular Redundancy (TMR) used in Xilinkx million gate FPGA. Recent work at LANL shows TMR version of a given design required 4X hardware → resulting design more sensitive to SEUs than a non-redundant design.
 - RTULP technique has only 2X hardware impact.

ULP Chips

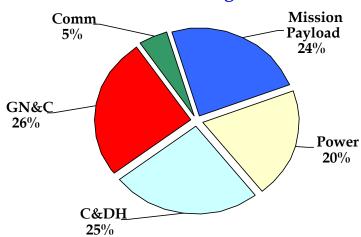
- CCSDS Lossless Data Compression Chip (RT ULP)
 - 450 Mbps @13 mwatts
- CCSDS R-S channel encoder (RT ULP)
 - 200 Mbps (a) 4 mwatts → tech demo on ST 5/NMP
- 8051 micro-controller (RT ULP)
- C50 DSP chip (ULP only)
- 500 Mhz correlator (RT ULP) for GSFC's radiometer (B3P4 by Principe, et al)
 - ECL design required ~ 20 watts.
 - Current RT ULP chip ~ 10 mwatts
- Cross correlator (RT ULP) (B3P4 by Principe, et al)
 - − < 1 watt for 25 channels over 200 Msamples/s</p>

CONTENT

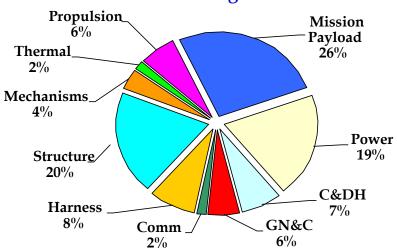
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Re-engineering with ULP

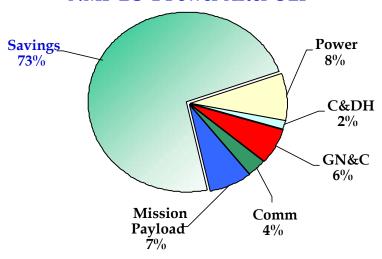
NMP EO-1 as Designed Power



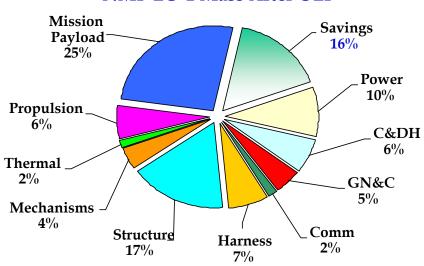
NMP EO-1 as Designed Mass



NMP EO-1 Power After ULP

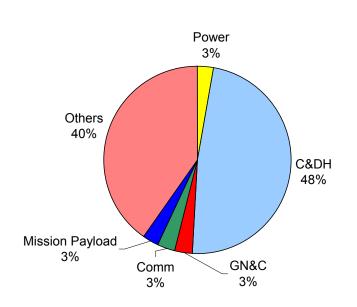


NMP EO-1 Mass After ULP

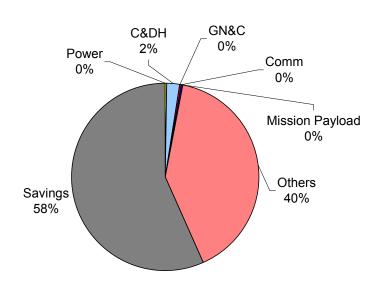


Potential Power Savings on ST5/NMP Using RT ULP

ST5 Power As Designed



ST5 Power After ULP

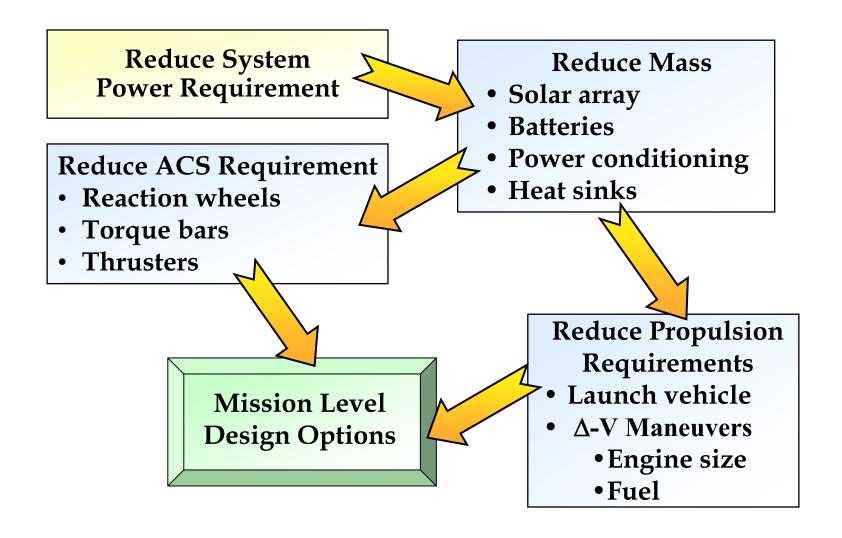


All analog power is included in "Others"

APL Study

- M. Freeman at APL/JPH, 1999 study report
 - Studied 5 missions:
 - Discover II: SAR
 - SLIC: passive sensors
 - FUSE: telescope, 1999
 - TIMED: Atmospheric Science, 2000
 - MSX: Sensor platform, 1996
 - Freeman's report: "We found load power reductions ranging from 20% to 41%, depending on the extent to which digital electronics are employed in the architecture."

The "Domino" Effect



Impact on Science

RT ULP enables NEW science instrument concept



e.g. Proposed Synthetic Thinned Aperture Radiometer (STAR) on GPM

Proposed STAR Instrument electronics: 2 channels with 25/19 receivers. Correlation for every pair of receivers.

- Projected correlator ASIC power > 40 watts
- Instrument electronics box limited to < 30 watts with control electronics, compression and H/K boards
- Projected RT ULP correlator power < 1 watt

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RT ULP Technology Features

Lower Power with 0.5 volt supply

- System level payoff studies on two missions
 - 50% spacecraft power reduction
 - 15% mass reduction realized from lower power

Performance Equivalent to 3.3 volt Commercial CMOS

Commercial Foundry Based

- Higher performance with respect to radiation hard foundries
- No cost to Government to support and upgrade foundry
- Follow commercial road map to smaller feature sizes
- Lower fabrication cost

Radiation Tolerant

- Latch-up Immune
- SEU tolerant
- Total dose tolerance projected to 1Mrad from back-bias

ULP Electronics

- 0.5 volt triple metal 0.35 micron CMOS process
 - Analog is coming up
 - Digital is quite solid, near completion
 - Four process runs completed at AMI
- Design Infrastructure
 - SPICE models (based on few runs)
 - Layout rules for RT and non-RT
 - Standard cell library in development
- 3.3 and 0.5 volt translation I/O pads

Future Work

- Complete RT ULP development for digital design —Automatic Back Bias generation
- Complete radiation test on devices from the ULP3 run
- Continue RT ULP work for analog/mixed signal
- Develop RT ULP components for S/C sub-systems
 - stable power supply converter and distribution components
 - DSP, general purpose processors, memory, ADC, protocol, etc.
- Research High Density design methodology to offset high mask cost for designs using features
- Develop mechanism for RT and ULP on smaller features: 0.25u and 0.18u
- Research Ultra Low Temperature potential capability